

A proposal for an unusually stiff and moderately ductile hard coating material: Mo_2BC

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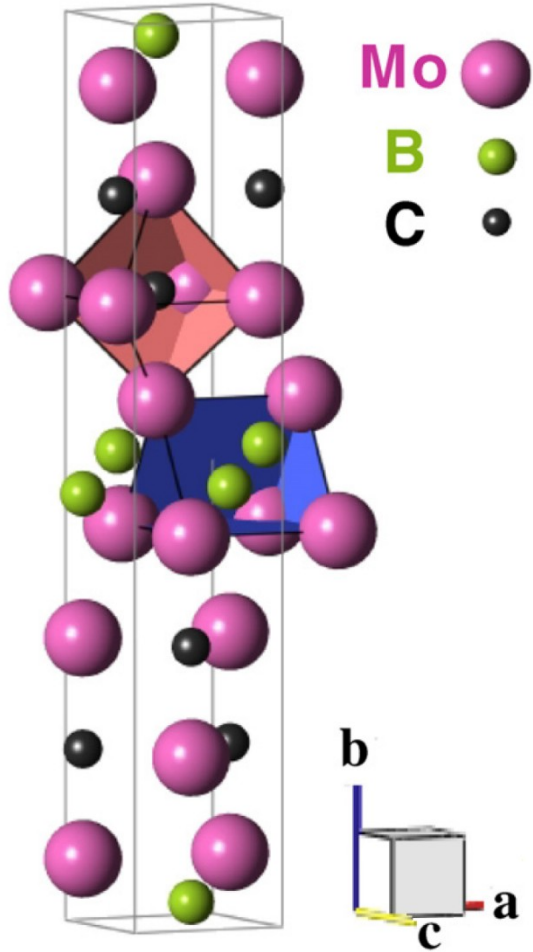
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Introduction

- Protection of tools – thin films
- Most thin films – hard but brittle
- Combination of hardness and moderate ductility to prevent formation and spreading of cracks
- Nanolaminate Mo_2BC
- Prepared by magnetron sputtering

Mo₂BC coatings



Material	B (GPa)	B/G
TiN	295	1,39
Ti _{0,25} Al _{0,75} N	178	1,44
c-BN	376	0,98
Mo ₂ BC	324	1,72

- Combination of great hardness and moderate ductility
- Stiff Mo-B and Mo-C layers with metallic interlayer bonding
- B – bulk modulus
- G – shear modulus
- $B/G > 1,75$ ductile materials
- Mo₂BC thin films were synthesized using DC magnetron sputtering on Al₂O₃ at a substrate temperature of ~900 °C

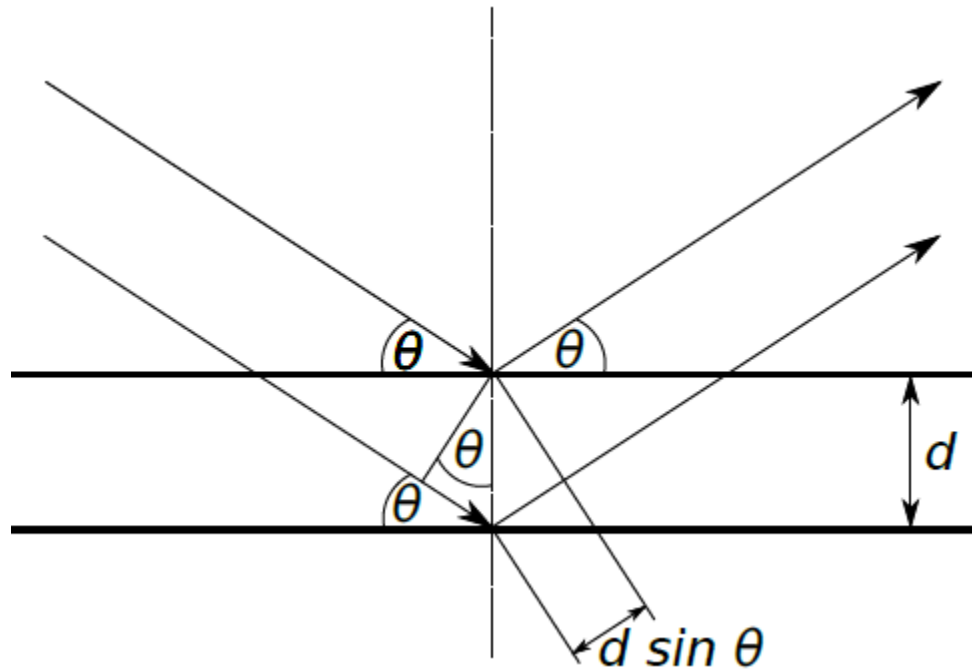
Used characterization methods

- X-ray diffraction
- Scanning electron microscopy
- Electron recoil detection analysis

X-ray diffraction (XRD)

- Information about the crystal structure
- Uses the scattering of photons on the atoms of the lattice
- The superposition of the scattered waves from individual atoms leads to classical reflection of light
- The incident rays are reflected from the atomic planes and interfere with each other
- Constructive interference occurs, when the Bragg condition is met

X-ray diffraction (XRD)

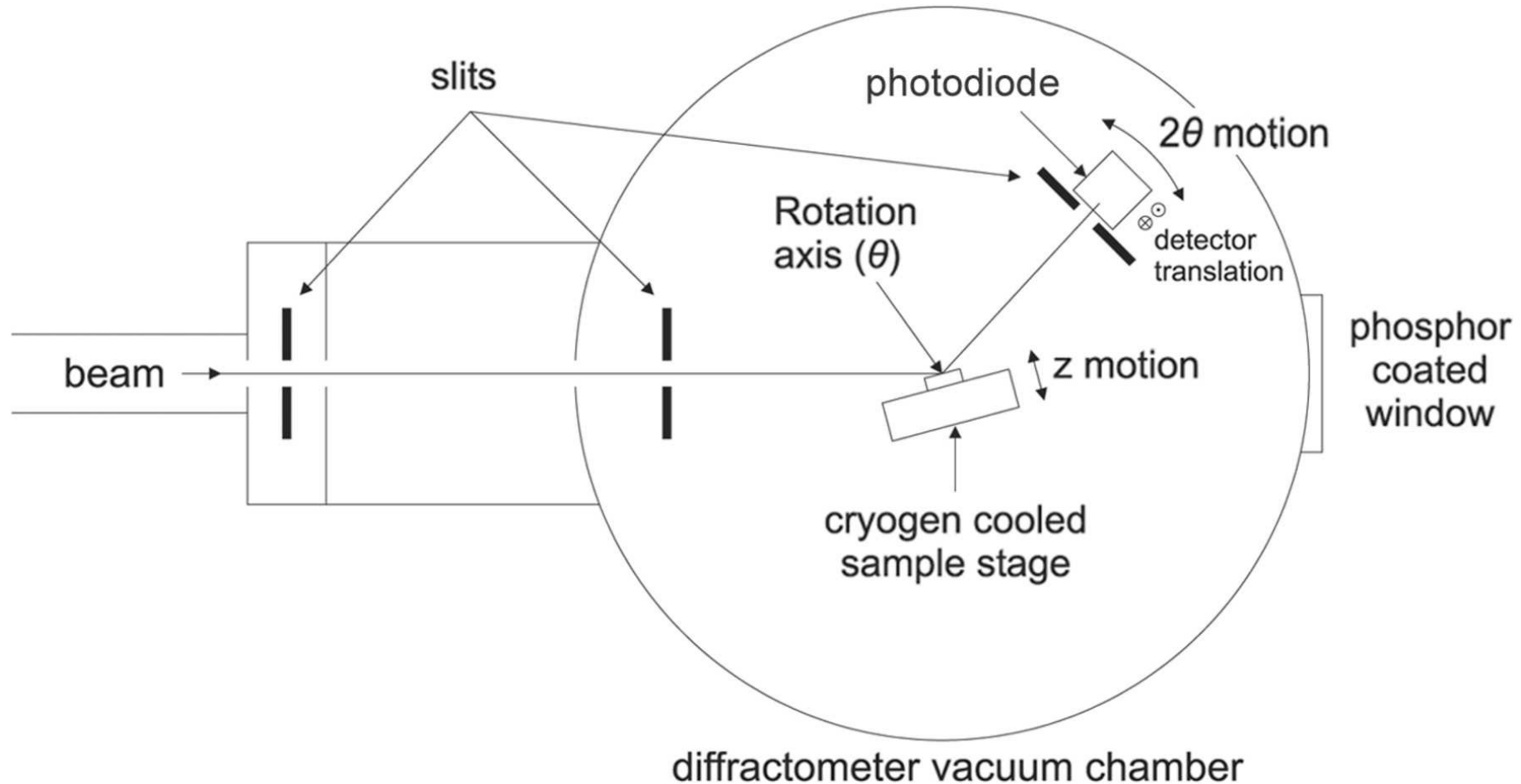


- The Bragg equation:

$$2d \sin \theta = n\lambda$$

- λ is the wavelength of the incident light,
 d is the distance between atomic planes,
 n is an integer and
 θ is the angle of incidence.

X-ray diffraction (XRD)



X-ray diffraction (XRD)

- Three methods of measuring:
 - Debye-Scherrer – monochromatic light and polycrystalline material
 - Laue – polychromatic light and monocrystalline material
 - Monochromatic light and monocrystalline material
- The combination of polychromatic light and polycrystalline material creates too many diffractions

X-ray diffraction (XRD)

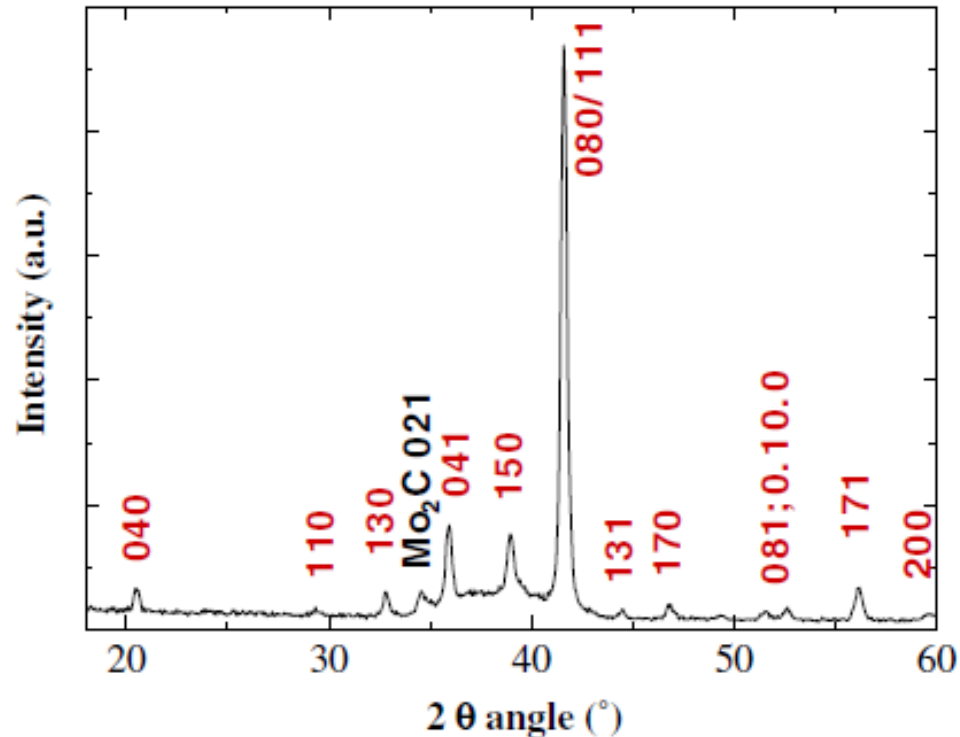


Figure 5. X-ray diffractogram of a Mo_2BC thin film deposited at $\sim 900^\circ\text{C}$ on $\text{Al}_2\text{O}_3(0001)$ substrate.

- The sample consists predominantly of Mo_2BC
- There is a minor contribution detected, stemming from Mo_2C
- Good agreement between the measured peak positions and the reference values
- The relative intensities of the diffractogram do not match due to the sample being textured

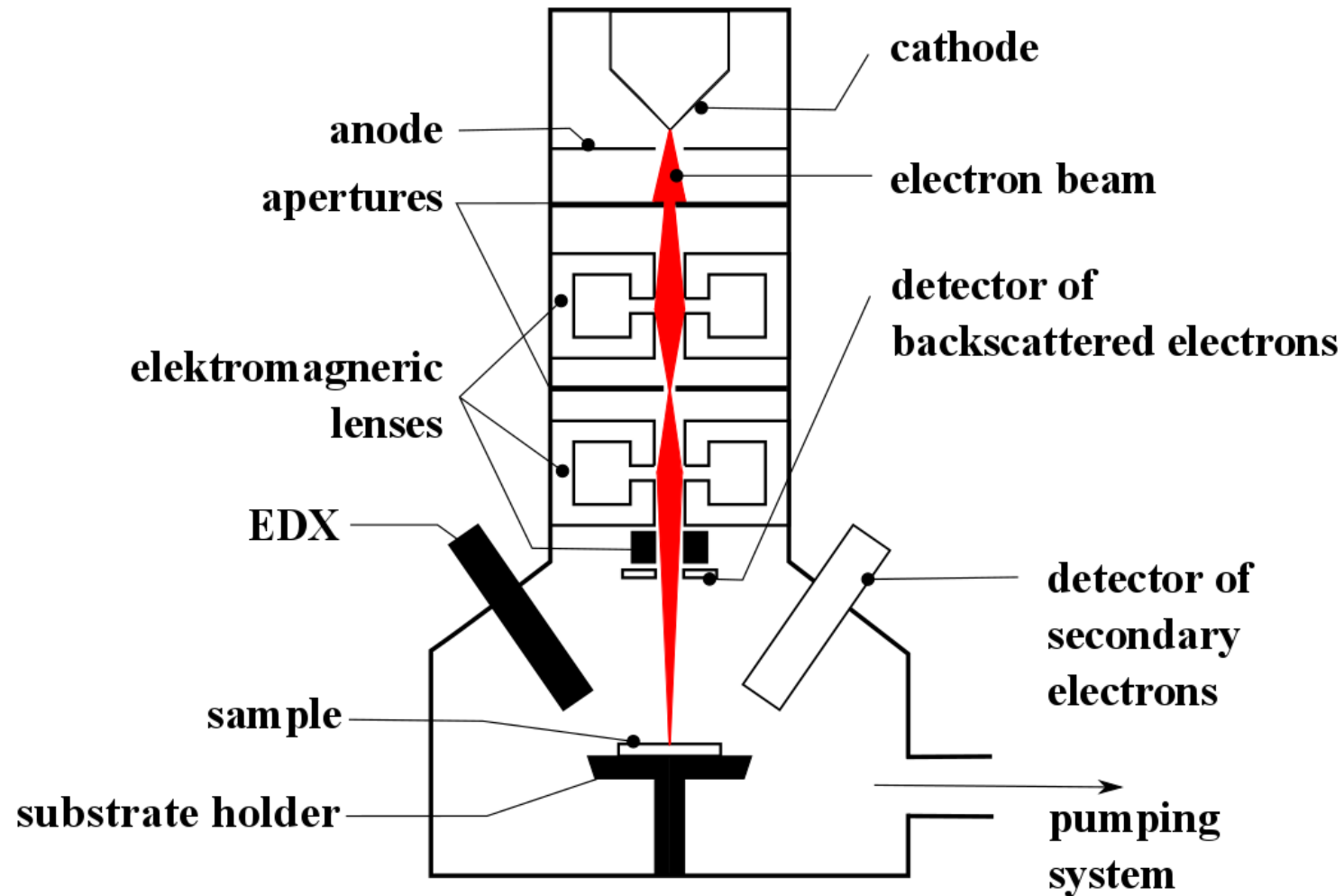
Scanning electron microscopy (SEM)

- Used for imaging of surfaces
- Focused beam of accelerated electrons
- The beam is focused and directed by electromagnetic lenses and scans the surface
- High vacuum is necessary to prevent collisions of electrons with gas particles
- Possibility to use with EDX or WDX to determine composition

Scanning electron microscopy (SEM)

- Two basic kinds of signal:
- Backscattered electrons
 - Electrons with high energy reflected from the surface
 - Greater penetration depth but worse spatial resolution
 - Number of reflected electrons depends on the atomic number of the particle – greater mass – more reflected electrons – brighter spot
- Secondary electrons
 - Electrons emitted from the surface due to inelastic scattering
 - Because of their low energy, only electrons created at the surface leave the sample
 - Mostly information about topography – electrons are emitted mostly from sharp edges

Scanning electron microscopy (SEM)



Scanning electron microscopy (SEM)

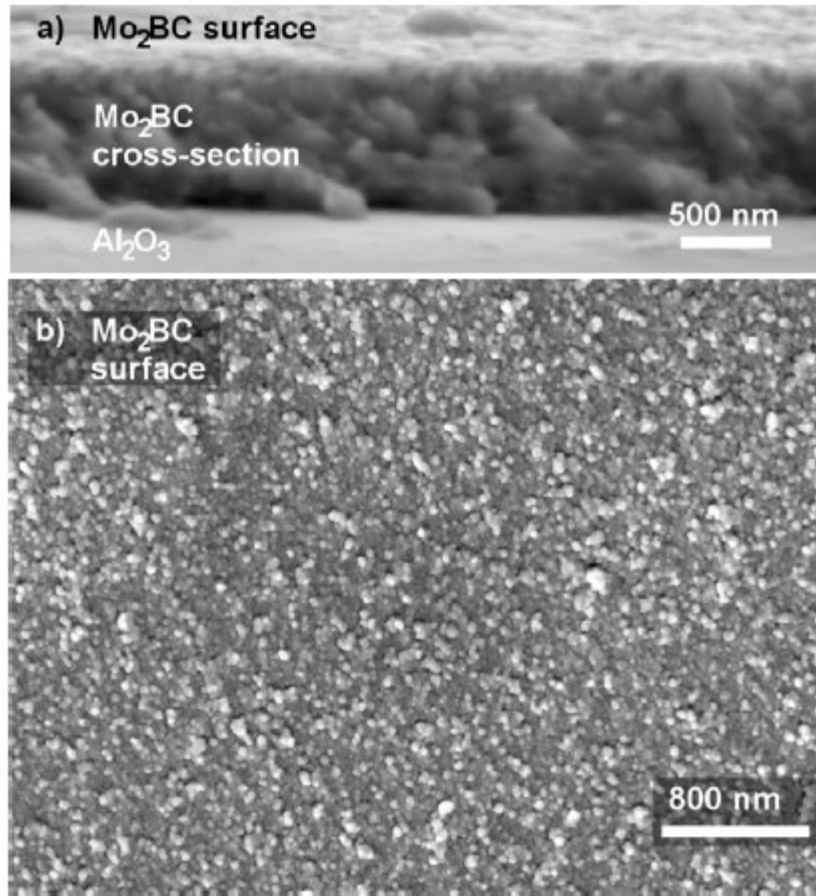
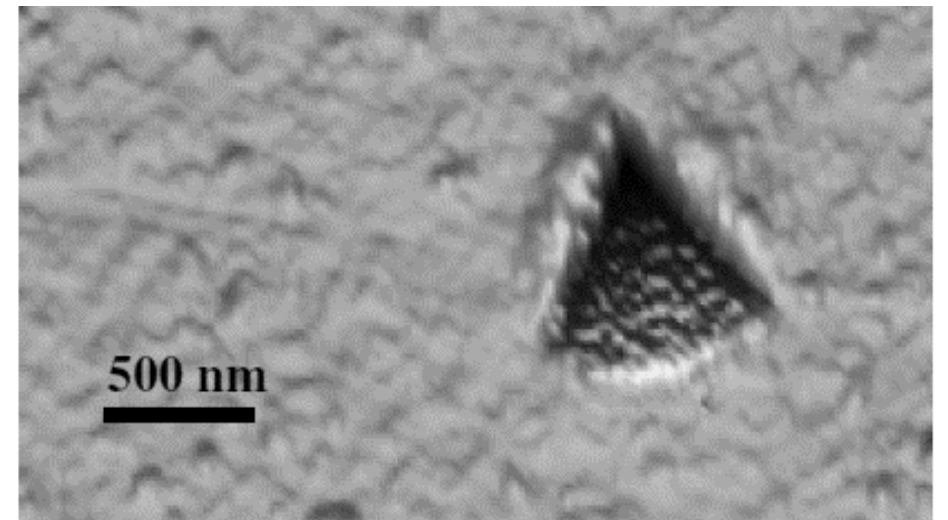


Figure 6. SEM image of (a) cross-section and (b) surface of a Mo₂BC thin film grown at $\sim 900^\circ\text{C}$ on Al₂O₃(0001).

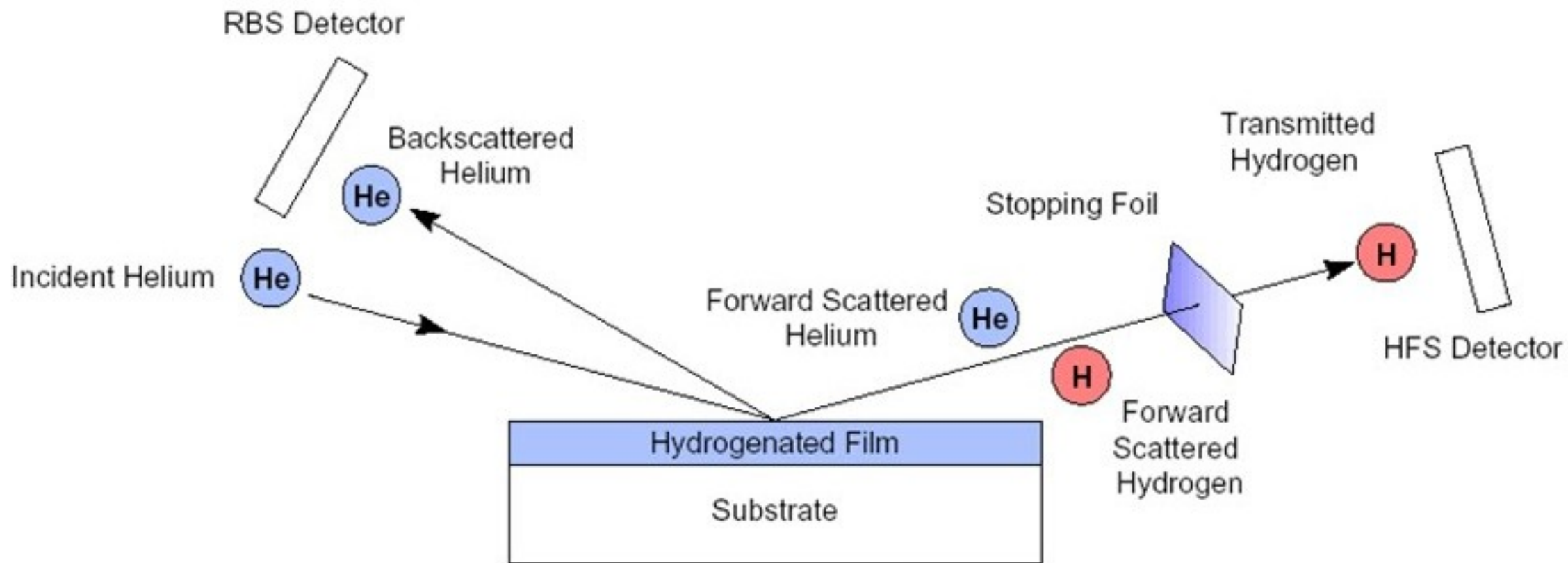
- No formation of pores or cavities
- Surface features with a diameter well below 100 nm
- No crack formation observed around the indent



Energy recoil detection analysis (ERDA)

- Detection of light elements in a heavy matrix
- Analysis of forward scattered ions or atoms
- A single collision
- Particles can be identified by their kinetic energy
- Analysis of particles: TOF, thin foil

Energy recoil detection analysis (ERDA)



Energy recoil detection analysis (ERDA)

- The film consists of 49 at% Mo, 27 at% B and 24 at% C
- The chemical formula $\text{Mo}_2\text{B}_{1.1}\text{C}_1$, which is very close to the nominal stoichiometry of Mo_2BC .
- O and H were not detected in the film.
- The variation of B from stoichiometric Mo_2BC composition is within the expected measurement error.

Conclusion

- Mo_2BC thin films were synthesized using DC magnetron sputtering on Al_2O_3 at a substrate temperature of ~ 900 °C.
- XRD measurements and ERDA confirmed that the grown film is almost phase pure and of near-stoichiometric composition
- No formation of cracks was observed implying moderate ductility
- Deformation experiments carried out with nanoindentation confirmed the high stiffness of Mo_2BC

Thank you for your attention!

J. Emmerlich, D.Music, M. Braun, P. Fayek, F. Munnik, J.M. Schneider, J. Phys. D: Appl. Phys. 42 (2009) 185406

Peter E.J. Flewitt, R.K. Wild: *Physical Methods for Materials Characterisation*, Series in Materials Science and Engineering

<https://sites.google.com/a/lbl.gov/rbs-lab/ion-beam-analysis/elastic-recoil-detection-analysis-erda>

<http://journals.iucr.org/s/issues/2005/04/00/kv5008/kv5008fig1.html>